Design Exercise 1

Double Slit Experiment - FDTD Simulation -

High-Speed Circuits & Systems Lab. Dept. of Electrical and Electronic Engineering Yonsei University

1885

Lumerical Solutions

3D Maxwell solver(FDTD)

Our Products



FDTD Solutions: Single and multiprocessor finite-difference timedomain optical design software. Product Details | Trial Download



MODE Solutions: Waveguide eigenmode solver and omnidirectional broadband propagator design software. <u>Product Details | Trial Download</u>



INTERCONNECT: Optoelectronic and photonic integrated circuit (PIC) design software package. Product Details | Trial Download

Z

DEVICE: Powerful semiconductor TCAD device simulation software for silicon-based optoelectronic structures.

Product Details Trial Download



Modal analysis(MODE)



Charge transport & heat transfer(DEVICE)





How To Download

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Optoelectronics (17/2)



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License Setting

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Actions
Apply these settings to my user account only
Make these settings the system defaults (requires elevation)
Configure my account to use system defaults
Later for a set for the set of the former for the set
Instructions on now to activate your floating license
View your active licenses in the Flexivet Publisher dashboard
OK Cancel



FDTD Window





Double Slit Experiment



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Simulation Setup





Build Screen







Build Screen

Edit rectangle name screen Geometry Material Ret	ations Graphical randori	24		an usa hath ((x, θ, c, c, c, n)	
х (µm) -20 х span (µm) 0,5	x min (µm)	-20, 25 -19, 75	or (x	min & max) fo	or setup	
y (μm) 0 y span (μm) 105	y min (µm) y max (µm)	-52,5	30Y stew		Ø x Perspective view	θ×.
z (μm) 0 z span (μm) 1	z min (µm) z max (µm)	-0,5				
 ✓ use relative coordinates M Edit rectangle 	////					
name screen Geometry Material Rota	ations Graphical renderi	ng	X2 view		Ø x V2 view	σ×
material PEC (Perfect Elect	rical Conductor)					
index units micro override mesh order from mesh order 2	m material database					
Grid attributes						
		<u> </u>	Cancel			



Build Slits

• Upper slit

ame top_slit Geometry M	1aterial Rotations Graphical rend		name top_slit Geometry Material Rotations Graphical rendering
x (µm) x span (µm) y (µm) y span (µm)	-20 x min (μm 0.5 x max (μm 6 y min (μm 2 y max (μm	a) -20.25 b) -19.75 c) 5 b) 7	material etch index see material database index units microns override mesh order from material database mesh order 1
z (μm) z span (μm) V use relative	0 z min (μm 1 z max (μm coordinates	a) -0.5 a) 0.5	Grid attributes grid attribute name
		<u>Q</u> K <u>C</u> ancel	QK Cancel

• Lower slit

Geometry Material Rotat	ions Graphical rendering	Geometry Material Rotations Graphical rendering
x (µm) -20 x span (µm) 0,5 y (µm) -6	x min (μm) -20,25 x max (μm) -19,75 y min (μm) -7	material etch index see material database index units microns
y span (µm) 2	у max (µm) -5	mesh order 1
z (µm) 0	z min (µm) -0.5	Grid attributes
✓ use relative coordinates		grid attribute name



Source Setup





Source Setup



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Wonsei University

Monitor Setup







Monitor Setup

simulation type All					
🔲 override global monitor s	ettings				
📃 use linear wavelength sp	pacing				
✓ use source limits		89	Edit frequency domain power mor	nitor	
wavelength 👻	min/max 👻	n	ame projection		
minimum wavelength (µr	n) 0.633		General Geometry Data	to record Spectral averaging and apodiz	ation Advanced
maximum wavelength (µr	n) [U,633		standard fourier transform		
frequency points 5			🔲 partial spectral average		
Set global monitor settings			🔲 total spectral average		
			-Fields	Poynting vector and power	
Edit frequency domain power monit	tor		V output Ex 🔲 output Hx	output Px	
ame projection			v output Ez 📄 output Hz	output Pz	
				📝 output power	
General Geometry Data to	record Spectral averaging and apodization A	dvanced			
monitor type Linear Y	•				
x (µm) 30	x min (µm) 30				
x span (µm) 0	x max (µm) 30				
y (μm) U	y min (µm) -50				
y span (µm) Too	y max (µm) bu				
z (µm) 0	z min (µm) 0				
z span (µm) 0	z max (µm) 0				<u>O</u> K <u>C</u> ancel
🖉 use relative coordinates					
down sample X 1					
down sample Y					
down sample z					



Simulation Setup





Simulation Setup

N Edit FDTD simulation	N Edit FDTD simulation
name FDTD	name FDTD
General Geometry Mesh settings Boundary conditions Advanced options	General Geometry Mesh settings Boundary conditions Advanced options
dimension Simple 2D simulation	x (µm) 0 x min (µm) -30
background index 1	x span (μm) 60 x max (μm) 30
simulation time (fs) 1000	u (um) 0
simulation temperature (K) 300	y span (µm) 100 y max (µm) 50
	$z (\mu m) = 0.5$
	2 span (µm) 1 2 max (µm) U.S
N Edit FDTD simulation	Edit FDTD simulation
name FDTD	name (FDTD
General Geometry Mesh settings Boundary conditions Advanced options	General Geometry Mesh settings Boundary conditions Advanced options
mesh type auto non-uniform 🔻	PML settings
Mesh accuracu	x max bc PML v type [uniaxial anisotropic PML (legacy) • Help me choose PML settings
dt stability factor U.99	y min bc PML v Same settings on all boundaries
simulations,	y max bc PML
mownerfituen accurate simulation you want	allow symmetry on all boundaries
How do I choose?	set based on source angle kappa 2
	bloch units SI
	kx polynomial 3
	ky min layers 12
	max layers 64
	extend structure through pml



Simulation Setup(Mesh)

Accurate simulation is required in slits!
 →Mesh setup







Simulation Setup(Mesh)

• Upper slit

Edit mesh override region	N Edit mesh over	ride region			
General Geometry	General Ge	ometry			
Image: Set maximum mesh step	x (μm x span (μm	-20 i) 2	x min (µm) x max (µm)	-21 -19	
∠ override x mesh dx (μm) 0.0527 ✓ override y mesh	y (μm y span (μm	i) 6 i) 3	y min (µm) y max (µm)	4.5 7.5	
dy (μm) 0.0527 ✓ override z mesh dz (μm) 1e-07	z (μm z span (μm) 0)) 1e-07	z min (µm) z max (µm)	-5e-08 5e-08	
	<table-cell> use relativ</table-cell>	ve coordinates			
QK Cancel					<u>Q</u> K <u>C</u> ancel

• Lower slit

💿 set maximum mesh step 💿 set equivalent index	× (μm) -20	x min (µm)	-21	
🔽 override x mesh	x span (µm) 2	x max (µm)	-19	
dx (μm) 0.0527	y (µm) -6	y min (µm)	-7.5	
🖉 override y mesh	y span (µm) 3	y max (µm)	-4.5	
dy (µm) 0,0527	z (µm) 0	z min (µm)	-5e-08	
dz (µm) 1e-07	z span (µm) 1e-07	z max (µm)	5e-08	



Simulation





Simulation Result

iacte Traa			·	M	Visualizer 1
jects nee					
OTD Analysis	Show result	view			0.6
					0.5-
					0.4-
Jame	Type				
model	Model).3-
screen	Rectangle			(0.2-
HeNe source	TFSFSource				0.1-
UpperSlit	Rectangle				\sim
LowerSlit	Rectangle				-50
monitor	DETMonitor			ſ	Attributes
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lower Vis	sualize 🕨	E			
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					Parameter:
					Attr
					monitor:E
					monitor:E
		2	x		monitor:E
					monitor:E
					•





Single Slit Experiments

Disable one of slits -> single slit experiment







Sweep Simulation





Slit Distance Sweep

• Sweep slit distance 4, 8, 12 μm

💓 Edit Parameter Sweep			\sim	?X						
Name: sweep Poromotoro										
Tupo Rongoo - Number et a	winte:									
Type nanges Number of p										
Name	Parameter Type	Start Stop	Units	Add						
new_parameter	▼ Number	0 0		Remove						
Model D Properties					sweep				/	
				Name: sween						
▷ screen	ource			Parameters						
▷ UpperSli		voon nositiv	on I	Type Ranges	 Number of points: 3 					
	Uppersite V	veep positiv		Name	Darameter	Type	Start	Stop	Units	
FDTD	esh	nner & I ow	ier sl	itomesme		Length	2	6	microns	Add
Results lowerme	esh			lowmesh	"model"lowermesh"v	Length	-2	-6	microns	Remove
Name	Result Operatio	1		up	model::UpperSlit::v	Length	2	6	microns	
				up Inv	um a dalut avva Cliture	Longth	-			
				low	::model::LowerSlitt:y	Length	-2	-0	microns	
				•		III			•	
			- 1	Results						
Advanced				Name	Result	Operation				
resave files after analysis				F						Add
				-	⊿ model	_				Remove
			<u> </u>		Objects					
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					PTUU			Suit		
					monite	or				
				Advanced	a 1.1					
				resave files	atter analysis					
									OK	Cancel



Simulation Result

• 4 μm, 8 μm, 12 μm





Design Exercise

- Sweep slit width(1, 1.5, 2 μm) and simulate both single slit and double slit experiment.
 (Distance between two slits: 12 μm, Distance from slit to monitor: 50 μm)
- Sweep distance from slit to monitor(10, 30, 50 μm) and simulate both single and double slit experiment.
 (Distance between two slits: 12 μm, Slit width: 2 μm)
- Show the results respectively, and compare & analyze the results.
- Due: 10/30 in class(Hard copy)

